1201,63407

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:	Nayfeh et al.)) I hereby certify that this paper is being deposited with the United States Postal Service as FIRST-CLASS mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on this date.		
Serial No.:	09/496,506)			
Filed:	February 2, 2000)	Date F-CLASS.WCM Registration	B, R on No. 43,874	
For:	SILICON NANOPARTICLE FIELD EFFECT TRANSISTOR AND TRANSISTOR MEMORY DEVICE))))		ley for Applicant From Proor	
Art Unit:	1741)	K. WEY.	FJONES 5-15-01	

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

In accordance with 37 C.F.R. §§1.56, 1.97 and 1.98, applicants through counsel

herewith:

Submit a copy of the publication set forth in the attached form PTO-1449 as

follows:

U.S. PATENT DOCUMENTS

PATENT NO.	PATENTEE	ISSUE DATE	CEN CEN
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R.W. Collins, P.M. Fauchet, I. Shimizu, J.C. Vial, T. Shimada and A.P. Alivisatos, *Luminescence Properties of Silicon Nanocrystals*, Advances in Microcrystalline and Nanocrystaline Semiconductor Symposium, Boston, MA, USA, Dec. 2-6, 1996 (abstract).

Shoutian Li, Stuart J. Silvers and M. Samy El-Shall, *Luminescence Properties of Silicon Nanocrystals*, Material Research Society Symposium Proceedings, Vol. 452, pp. 141-6, 1997.

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U.S. Patent Application Nayfeh et al., Serial number 09/572,121 entitled SILICON NANOPARTICLE MICROCRYSTAL NONLINEAR OPTICAL DEVICES, filed on May 17, 2000.

U.S. Patent Application Nayfeh et al., Serial number 09/426,204 entitled SILICON NANOPARTICLE STIMULATED EMISSION DEVICES, filed on October 25, 1999.

U.S. Patent Application Nayfeh et al., Serial number 09/426,389 entitled SILICON NANOPARTICLE AND METHOD FOR PRODUCING THE SAME, filed October 22, 1999.

REMARKS

Applicants respectfully request that the Examiner consider the above-listed references in the examination of this application and list these references of record in the application.

Respectfully submitted,

GREER, BURNS & CRAIN, LTD.

Date: May 3, 2001

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